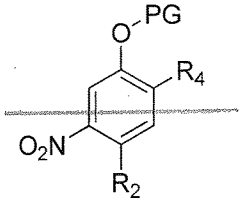
(b) hydrolyzing the methoxycarbonyl protecting group from the phenolic oxygen atom of Compound **33** by treating compound **33** with NaOMe/MeOH in 2-methyl tetrahydrofuran to provide Compound **34**; and

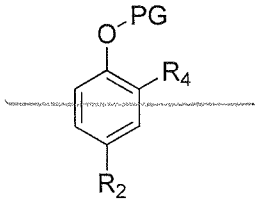
(c) forming a slurry of compound **34** in acetonitrile and water to provide Compound **34** in a pure form.

~~14. A process for the preparation of a compound of Formula 8~~



~~Formula 8~~

~~comprising nitrating a compound of Formula 7 using a mixture of sulfuric acid and nitric acid in the presence of dichloromethane~~



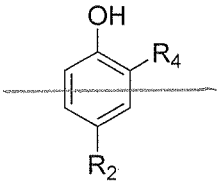
~~Formula 7~~

~~wherein PG is a protecting group and R_4 and R_2 are *tert*-butyl, and wherein the nitro compound of Formula 8 is purified by crystallization.~~

~~15. The process of claim 14, wherein PG is propoxy formyl, methanesulfonyl, 4-nitro-benzoyl, ethoxy formyl, butoxy formyl, *t*-butoxy formyl, *i*-propoxy formyl or methoxy formyl.~~

~~16. The process of claim 15, wherein PG is methoxy formyl.~~

~~17. The process of claim 14, further comprising producing a compound of formula 7 by reacting a compound of Formula 6~~



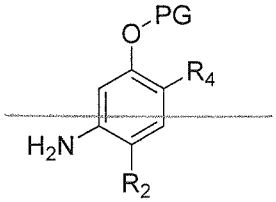
Formula 6

with a reagent capable of causing a protecting group to be attached to the phenolic oxygen of a compound of Formula 6 in the presence of a solvent.

18. The process of claim 17, wherein the solvent is diethyl ether, or methylene chloride.

19. The process of claim 18, wherein the solvent is methylene chloride.

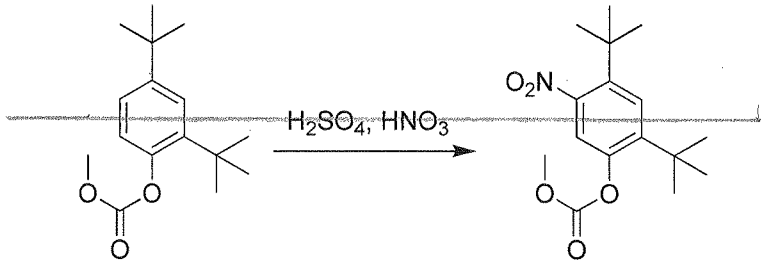
20. The process of claim 14, further comprising producing a compound of Formula 5



Formula 5

by reducing a compound of formula 8.

21. A process for the preparation of Compound 31, comprising contacting Compound 30 with a mixture of nitric acid and sulfuric acid in the presence of dichloromethane



30 31

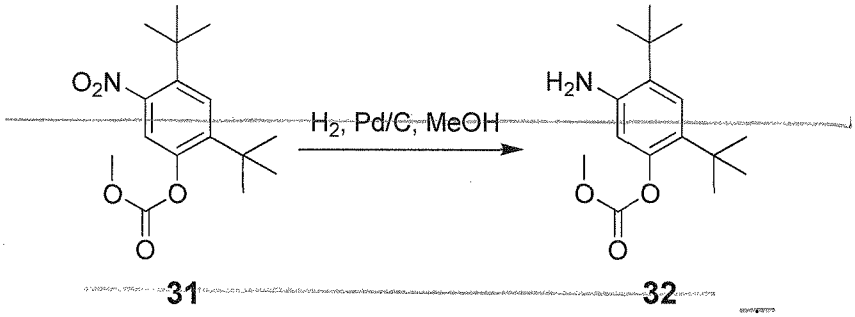
22. The process of claim 21, wherein the reaction is quenched by adding the reaction mixture to cold water.

~~23. The process of claim 21, wherein the aqueous layer is extracted with dichloromethane.~~

~~24. The process of claim 23, wherein the dichloromethane is further washed with water.~~

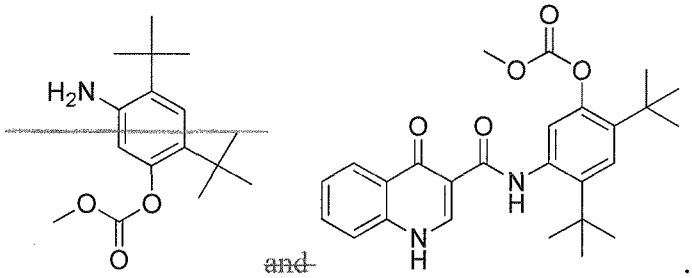
~~25. The process of claim 21, wherein the product is isolated by crystallization with hexane.~~

~~26. The process of claim 21, further comprising contacting Compound 31 in the presence of hydrogen gas, palladium on carbon, and methanol to provide Compound 32~~



~~31~~ ~~32~~

~~27~~14. A compound selected from:



~~and~~ .